

Refine Search

Search Results -

Terms	Documents
L2 and (nitrogen same polysilicon).clm.	10

Database:

US Pre-Grant Publication Full-Text Database
 US Patents Full-Text Database
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L5

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Search History

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result set

DB=PGPB,USPT,USOC,EPAB,JPAB,DWPI,TDBD; PLUR=YES; OP=ADJ

<u>L5</u>	L2 and (nitrogen same polysilicon).clm.	10	<u>L5</u>
<u>L4</u>	L2 and (nitrogen same polysilicon)	56	<u>L4</u>
<u>L3</u>	L2 and (nitrogen near7 polysilicon)	16	<u>L3</u>
<u>L2</u>	L1 and ((implant\$ or doing or dopannt) near7 polysilicon)	538	<u>L2</u>
<u>L1</u>	(polysilicon near3 line) same pattern\$	2233	<u>L1</u>

END OF SEARCH HISTORY